

Vertical 2D Crystal Hetero-structures: The Preparation, Device Application and Selective Growth

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Outline

◆ Introduction

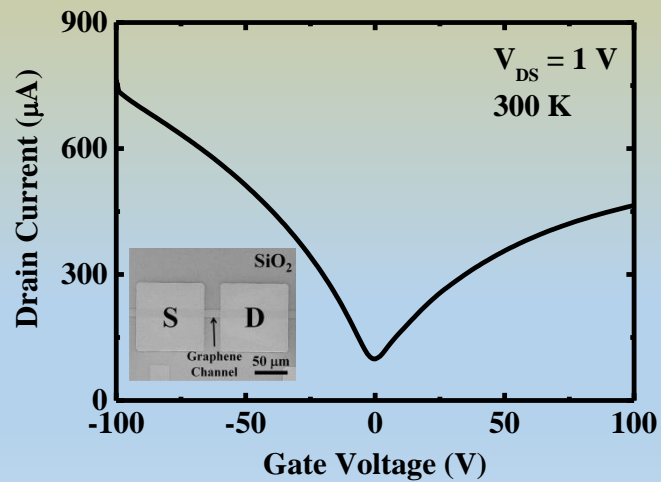
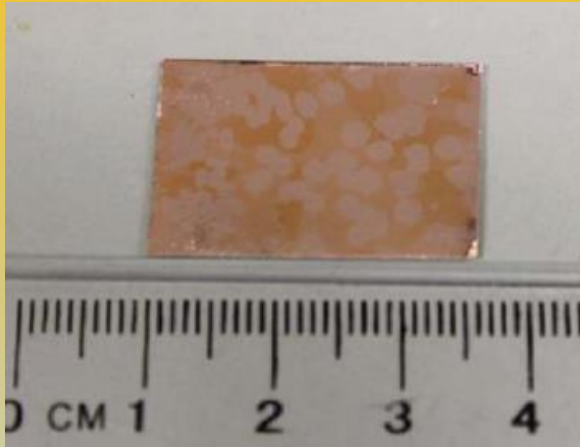
- The development of 2D materials
- Approaches to obtain 2D materials

◆ Results and Discussions

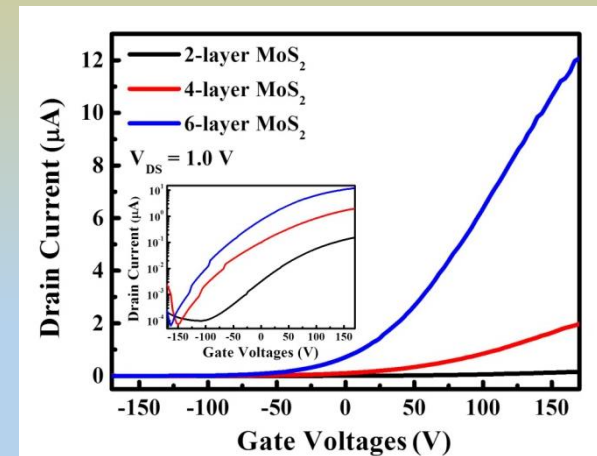
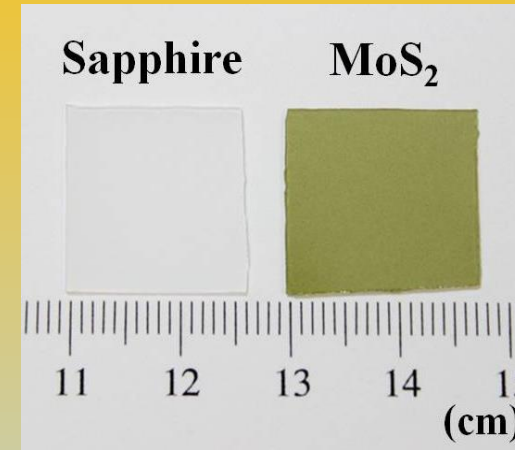
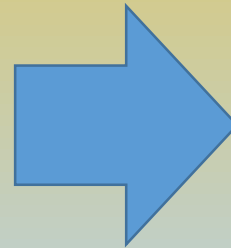
- The growth mechanism
- The establishment of 2D crystal hetero-structures
- Selective growth of 2D crystals

◆ Conclusion

The Development of 2D Materials

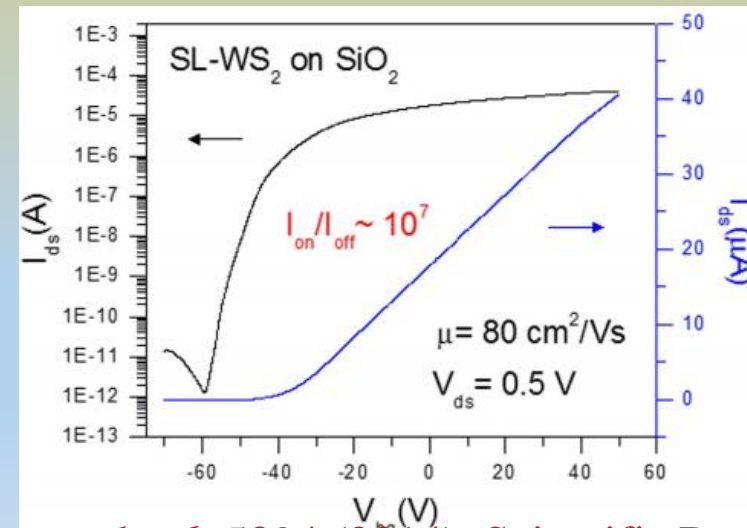
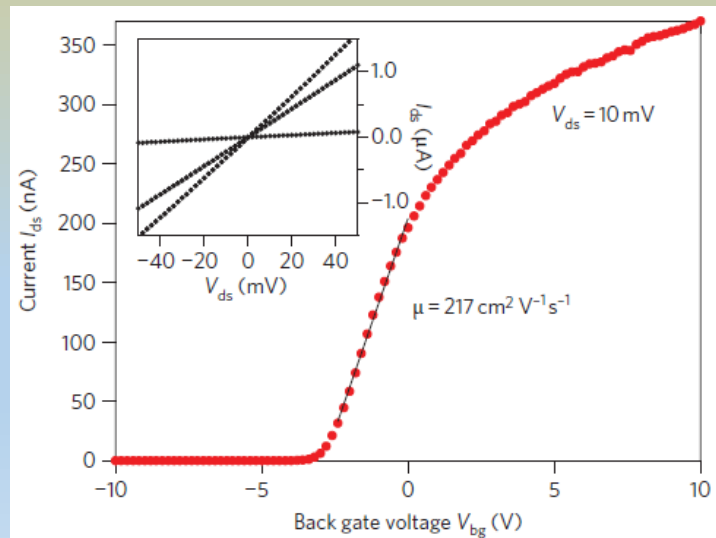
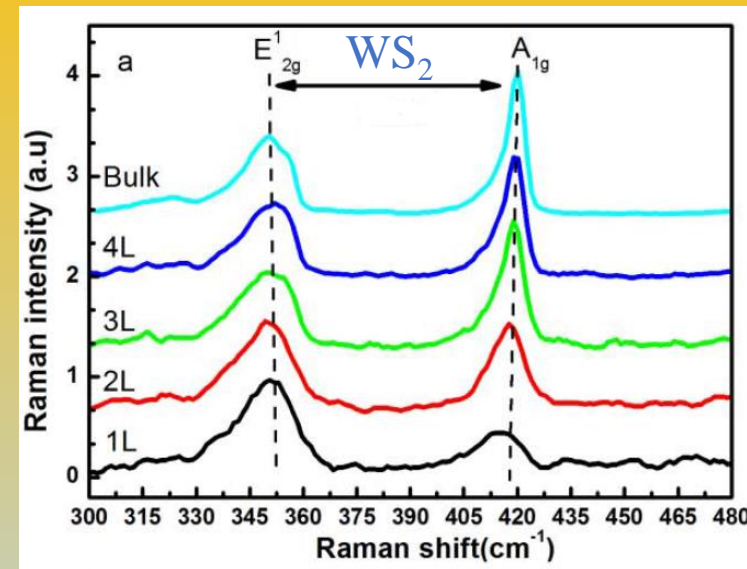
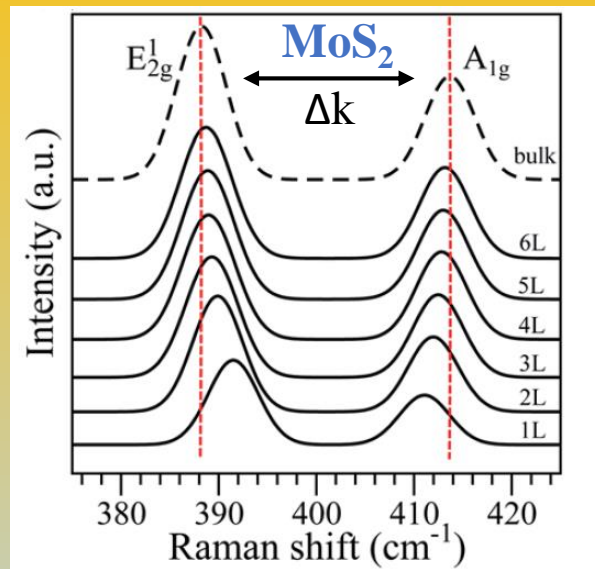


Graphene Transistors
High mobility, low ON/OFF ratios



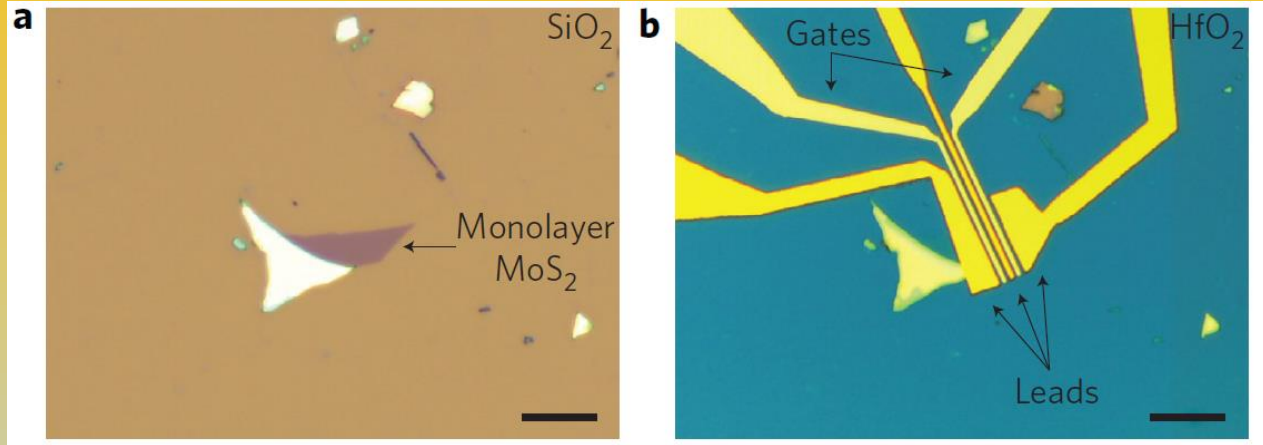
MoS₂ Transistors
Lower mobility, high ON/OFF ratios

Transition Metal Dichalcogenides (TMDs)



Nanoscale, **6**, 5394 (2014), Scientific Reports, **3**, 1608 (2013), Nature Nanotechnology, **6**, 147 (2011), Scientific Reports, **5**, 10699 (2015)

Approaches to Obtain 2D Materials



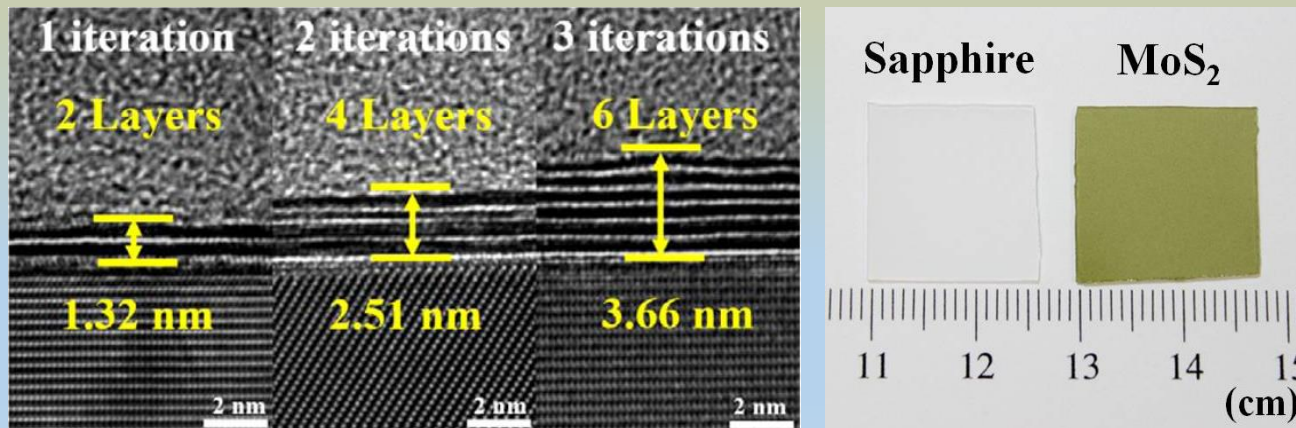
Mechanical Exfoliation

Advantage:

1. Easy to obtain single-crystal 2D material flakes
2. Good device performance

Disadvantage:

1. Large-area films are not available
2. Difficult to establish hetero-structure



Chemical Vapor Deposition

Advantage:

1. Good layer number controllability
2. Wafer-scale film growth

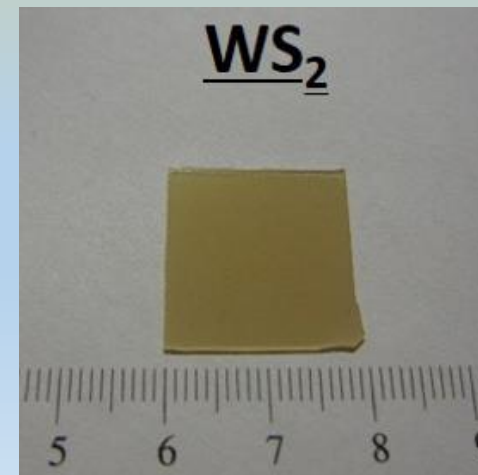
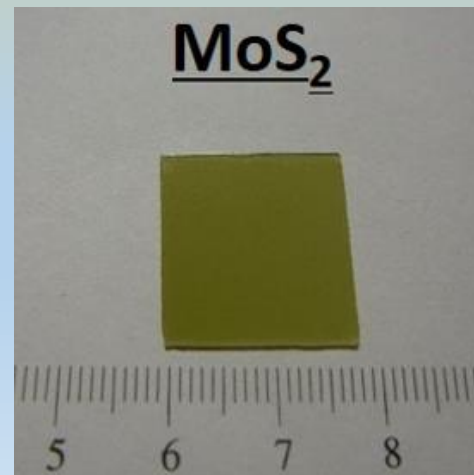
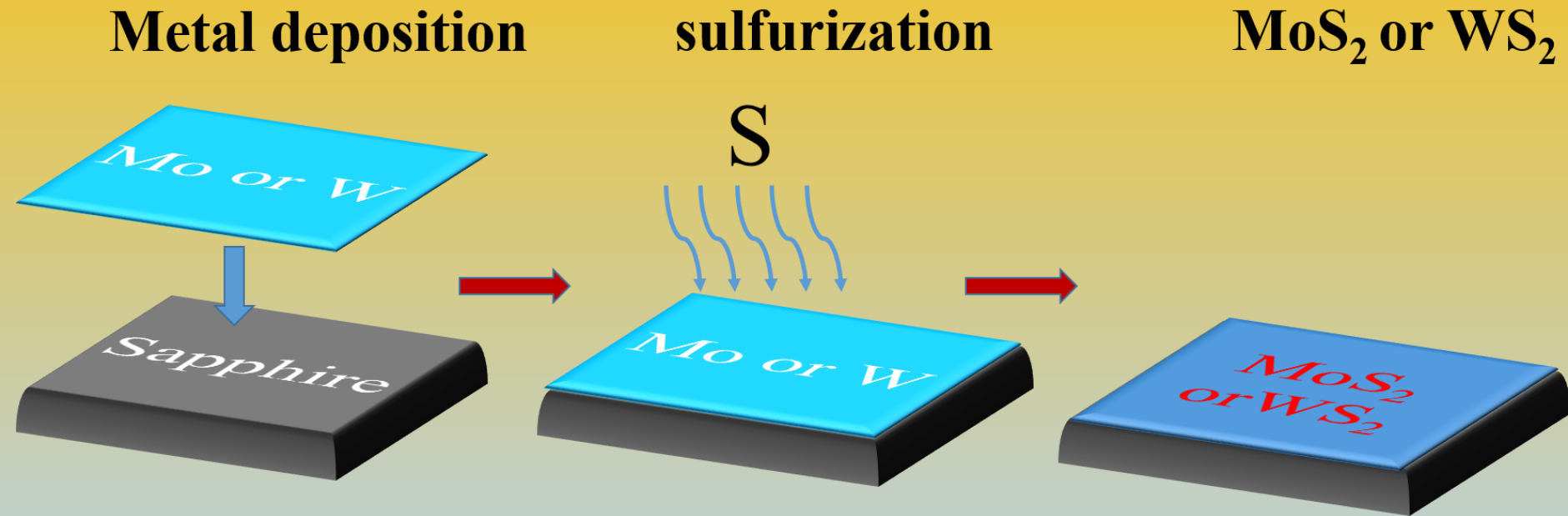
Disadvantage:

1. The choices of precursors
2. Difficult to achieve selective growth

Nature Nanotechnology **6**, 147–150, 2011

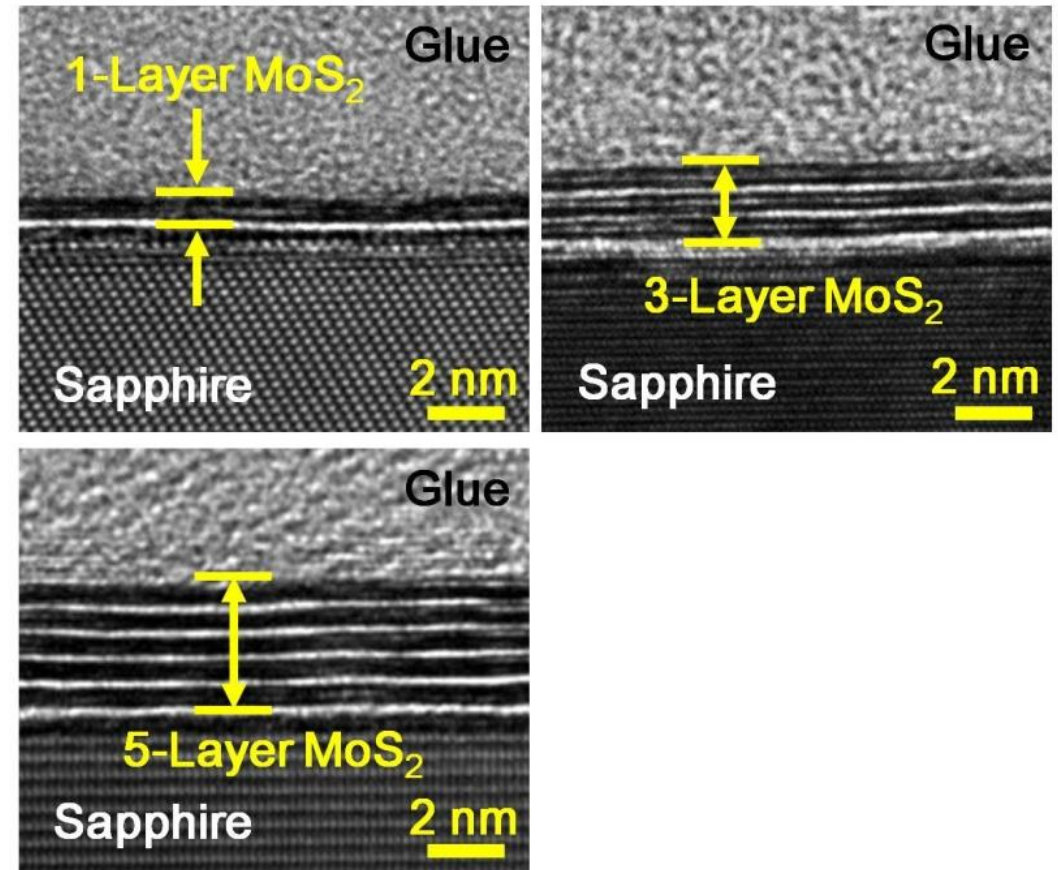
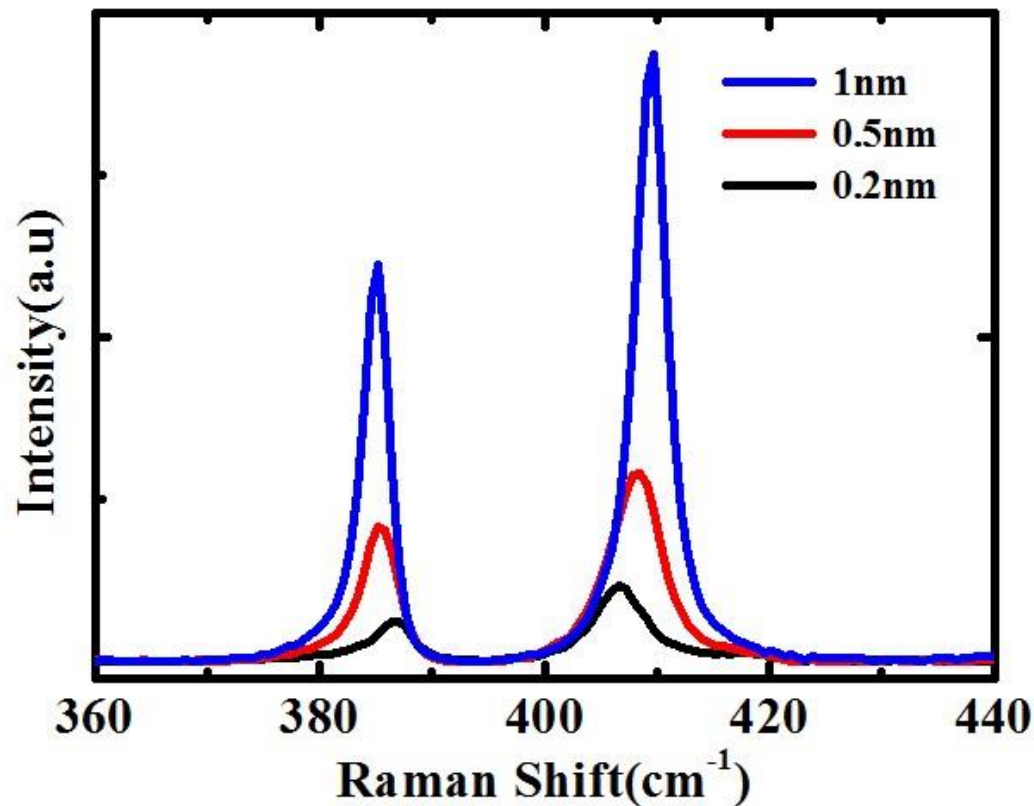
J. Phys. D: Appl. Phys. **48**, 435101, 2015

TMD Films Grown by Using Sulfurization of Pre-deposited Transition Metal films



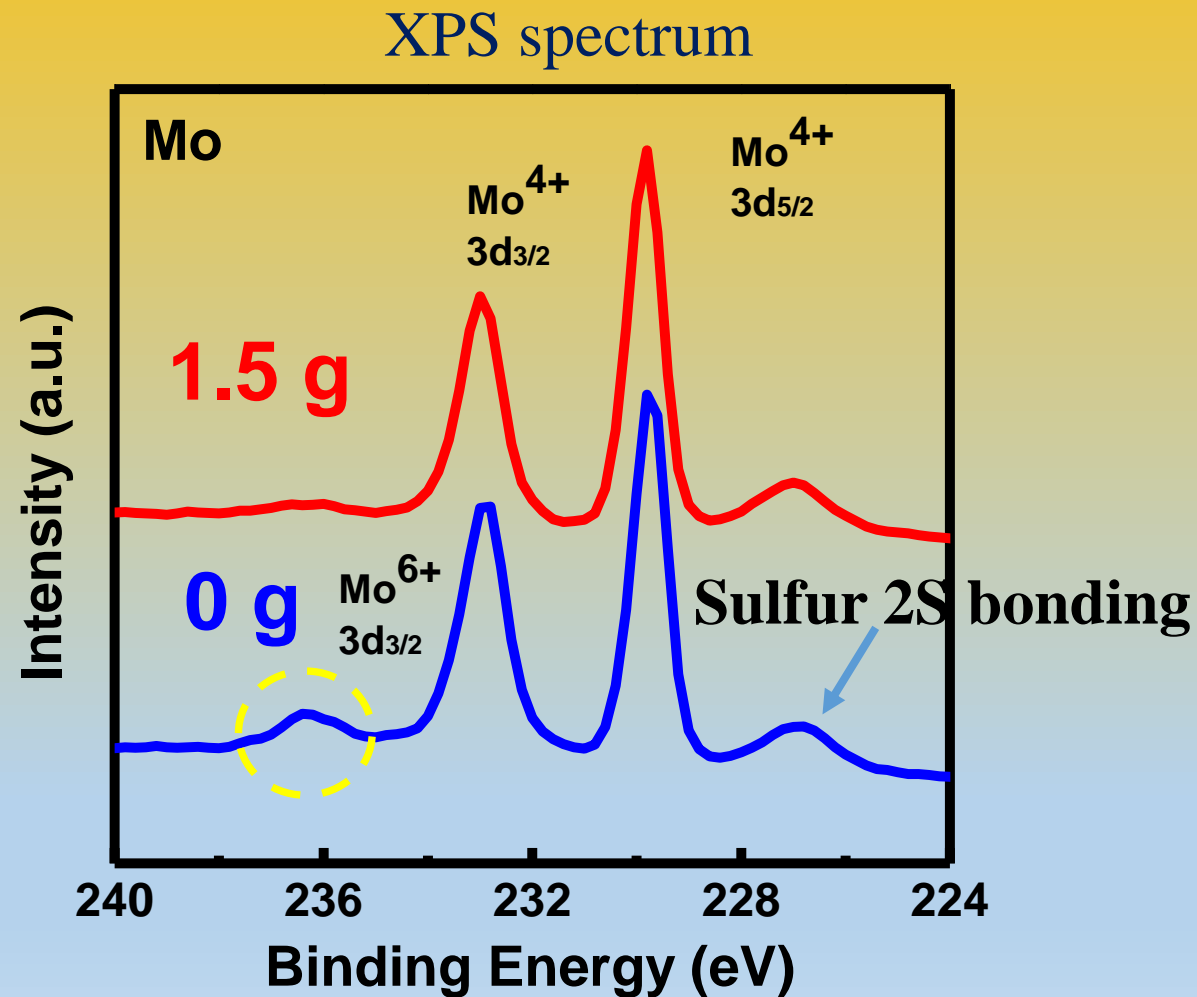
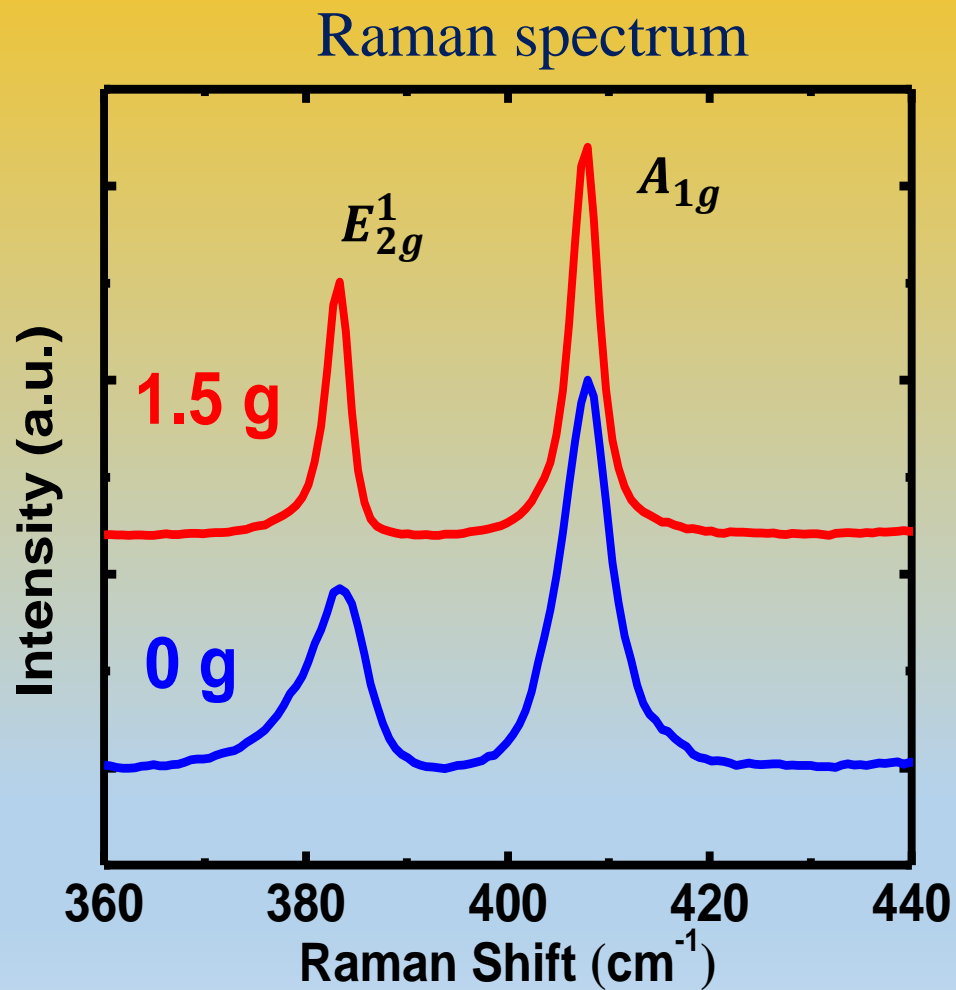
Results and Discussions

Layer Number Controllability of MoS₂



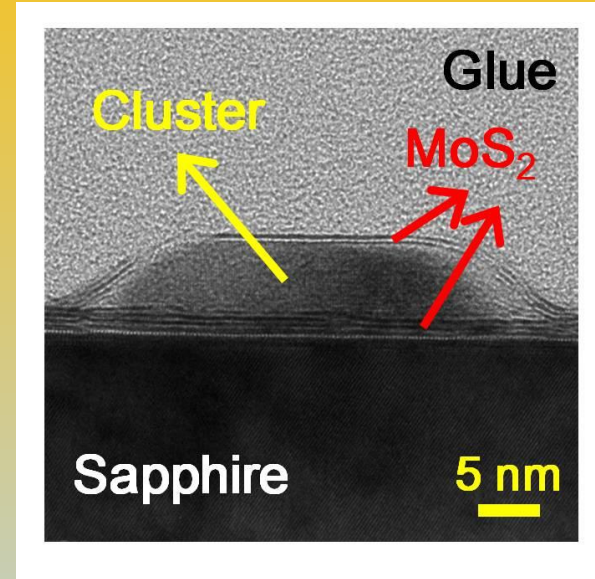
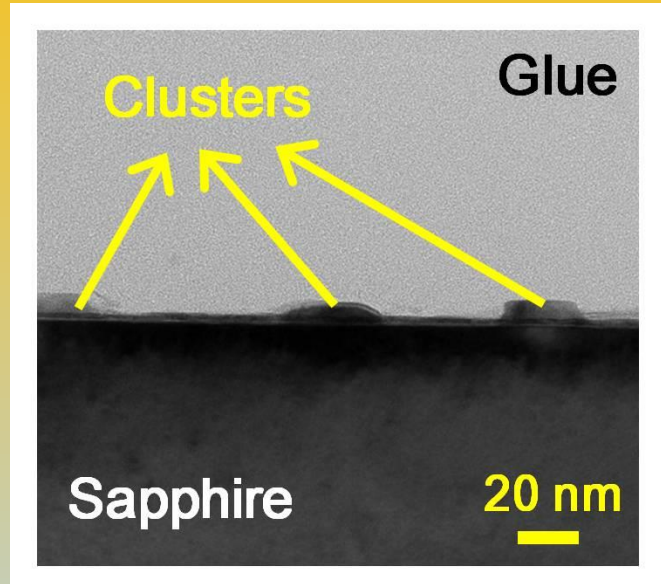
MoS₂ films grown through sulfurization of pre-deposited Mo films with different thicknesses on sapphire substrates

Sulfurization under Sulfur Deficient Condition

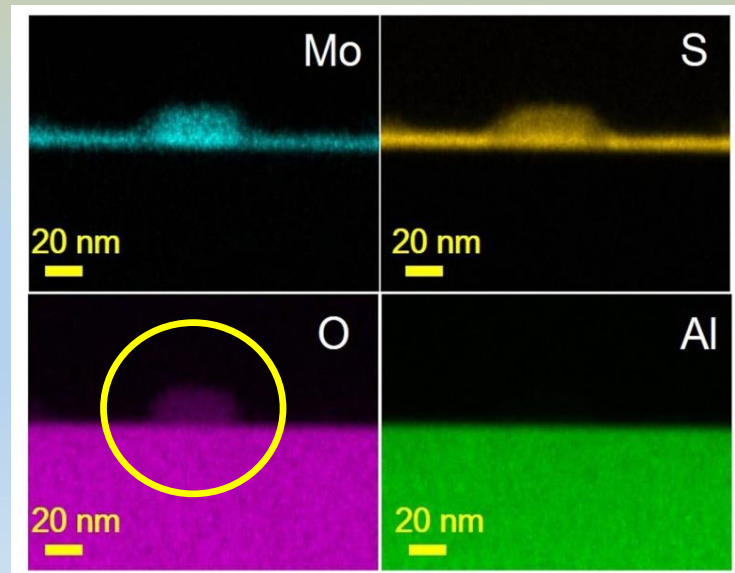


Sulfurization under Sulfur Deficient Condition

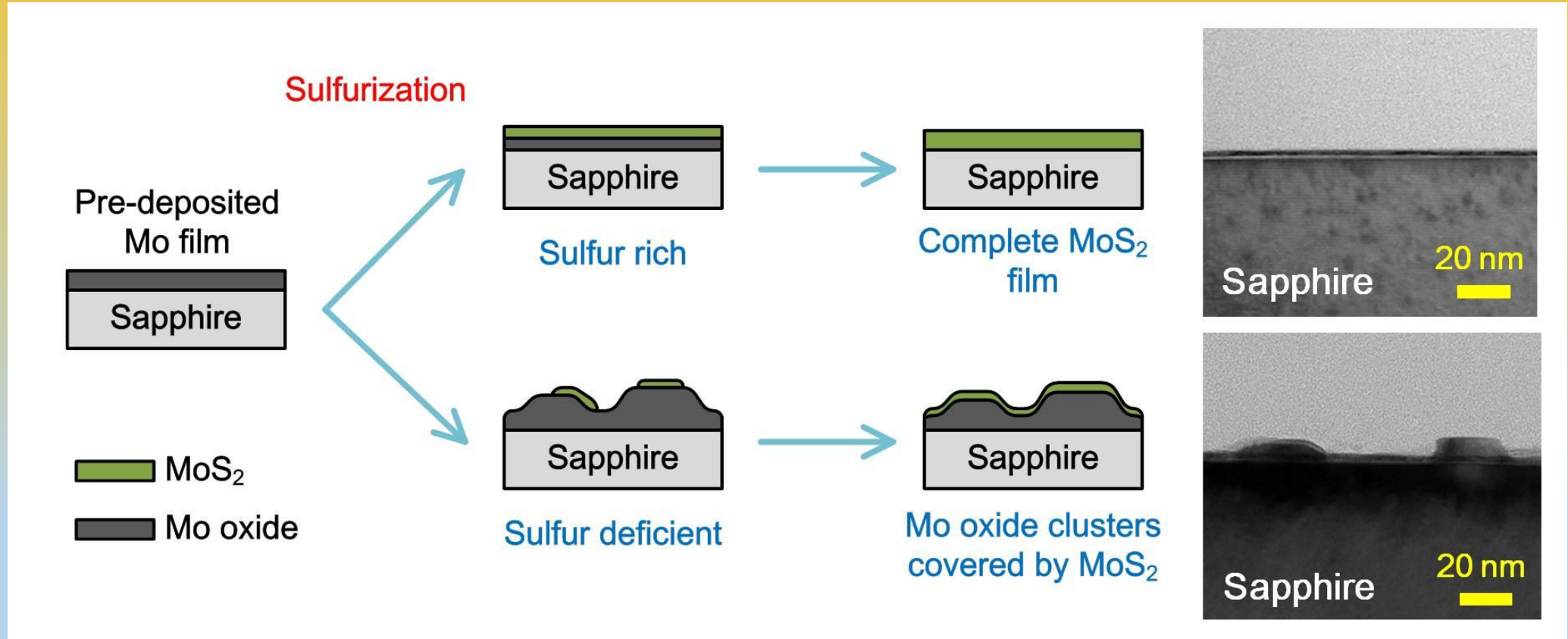
small clusters spreading over the sample surfaces



the cluster are covered with layered MoS₂ films

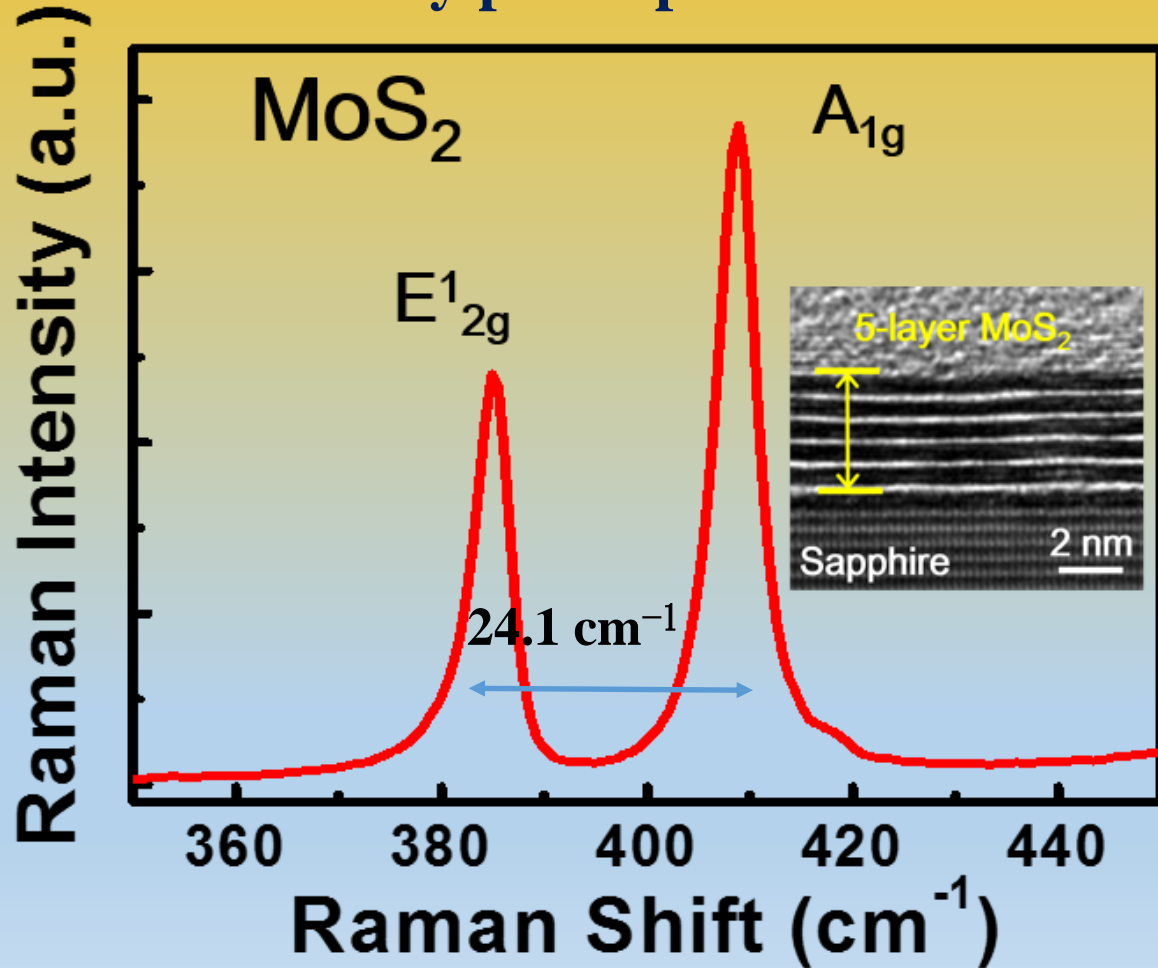


The Growth Model of Transition Metal Sulfurization

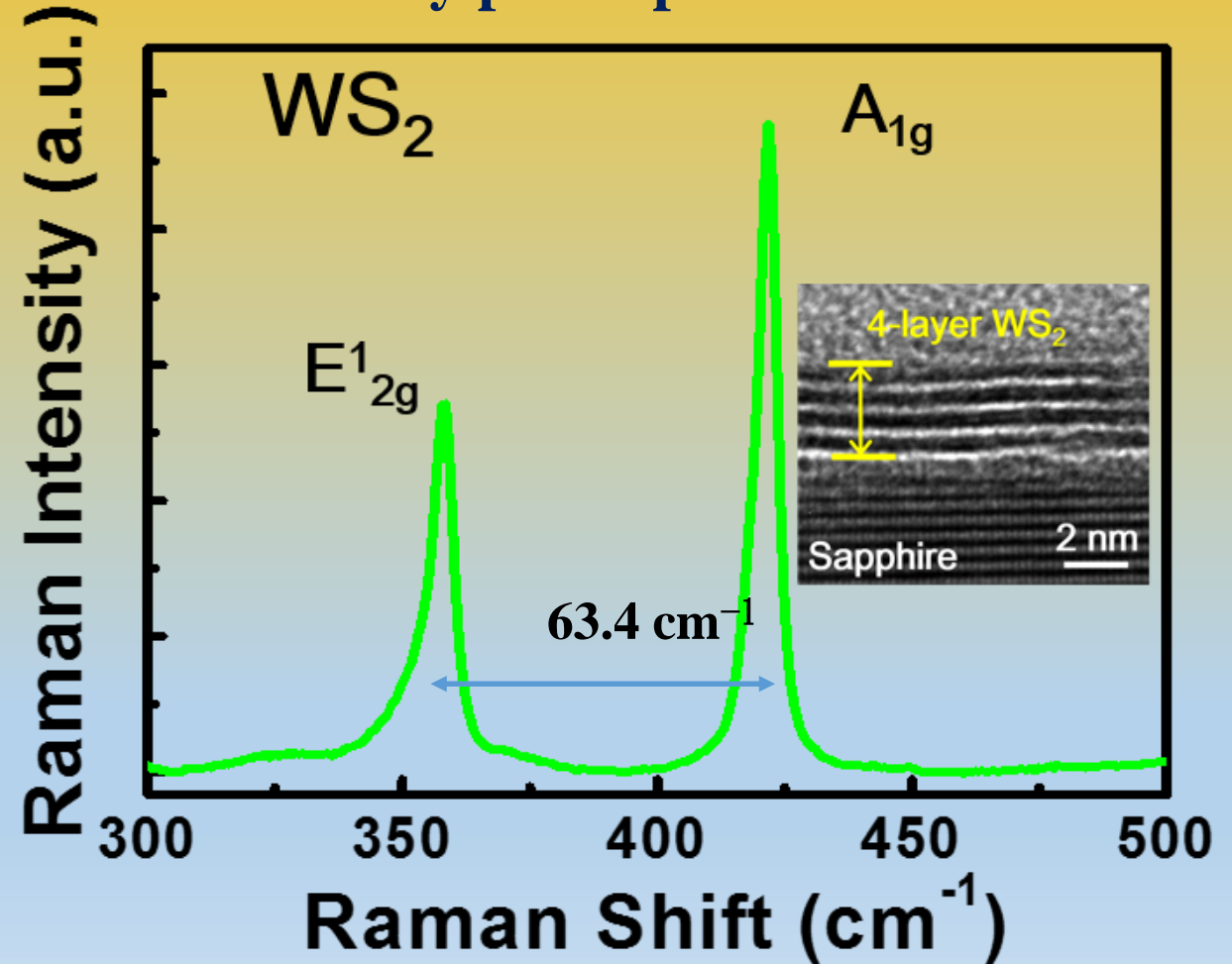


The Establishment of 2D Crystal Hetero-structures

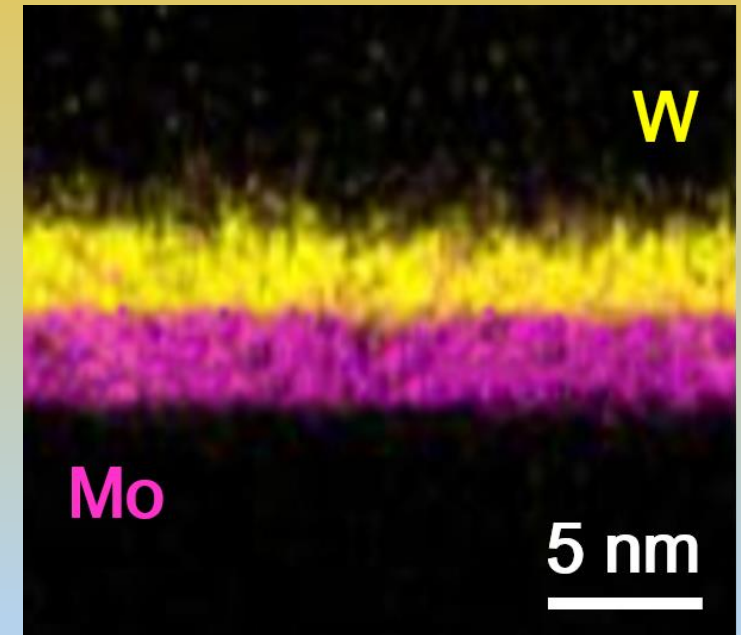
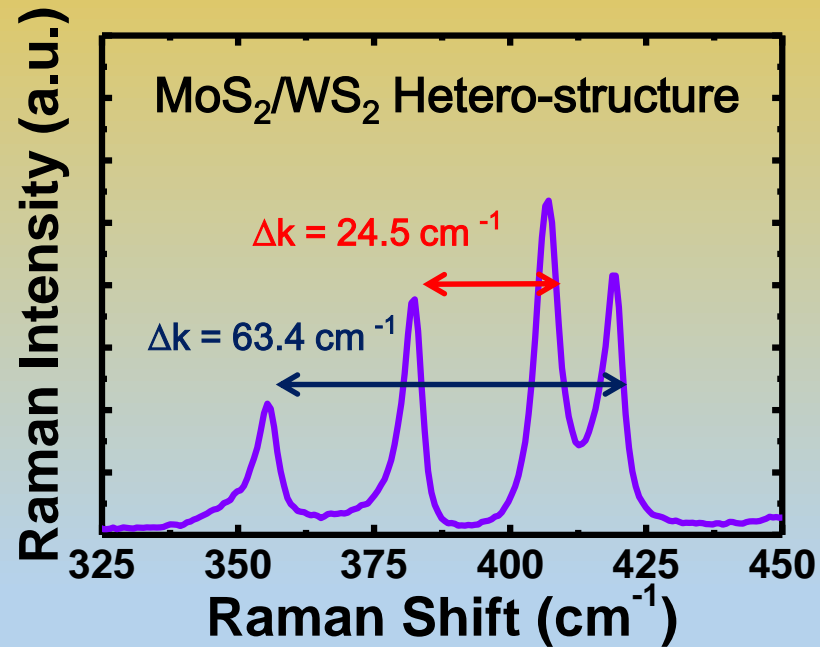
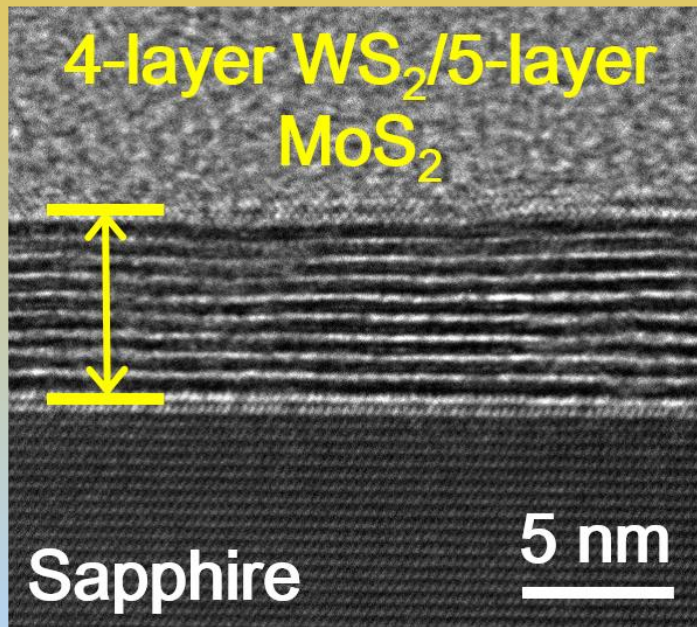
By pre-deposited 1 nm Mo



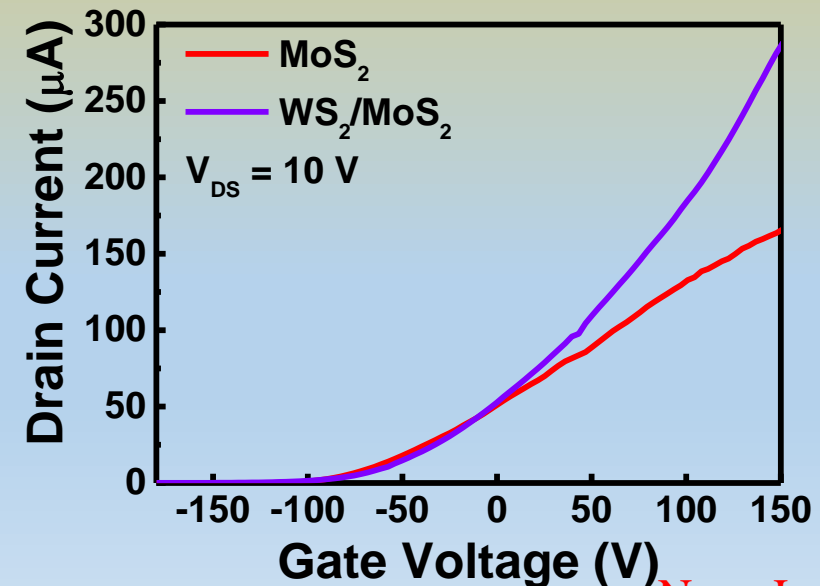
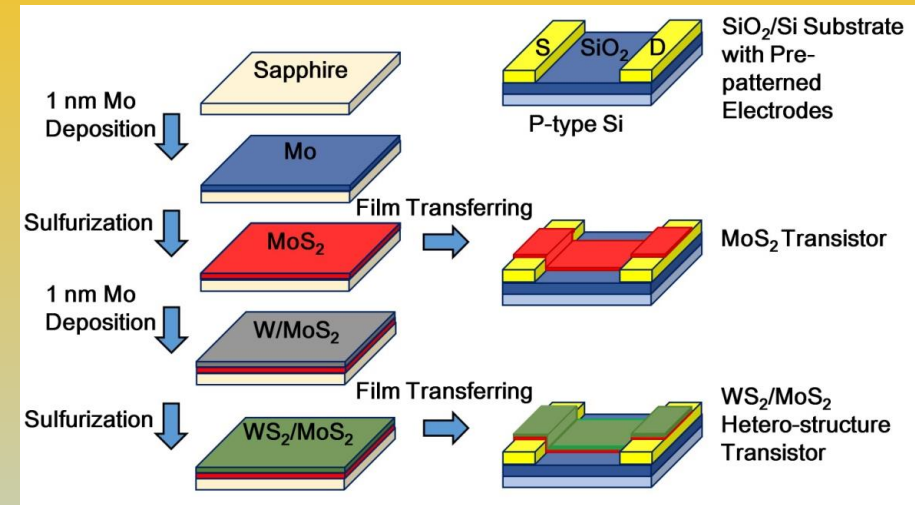
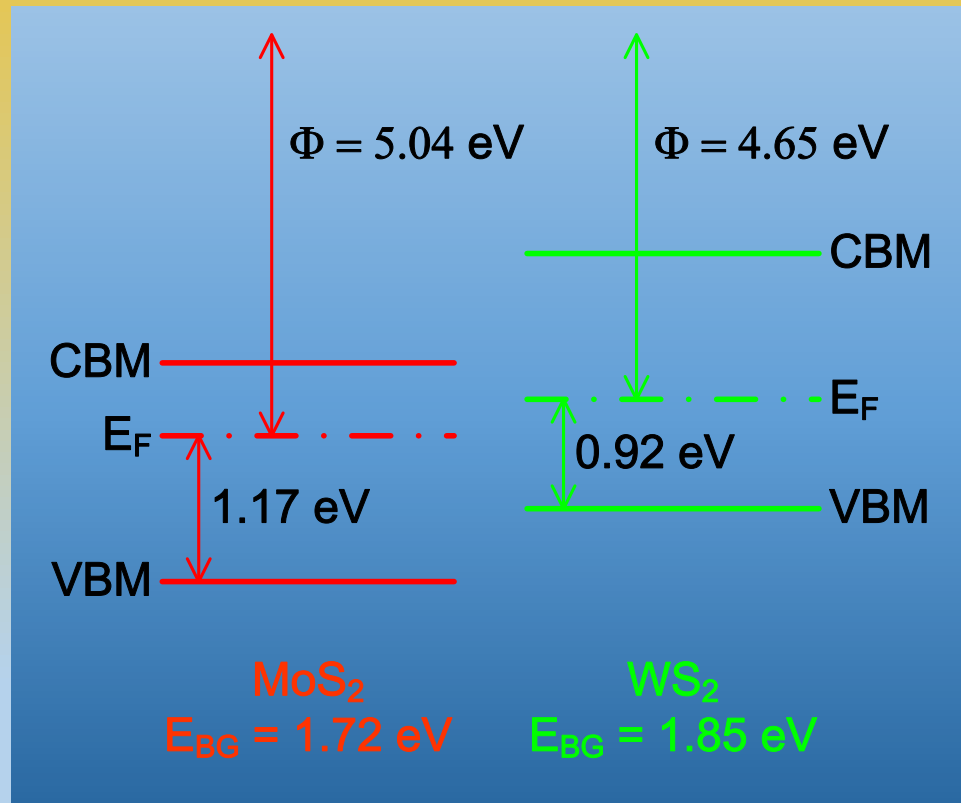
By pre-deposited 1 nm W



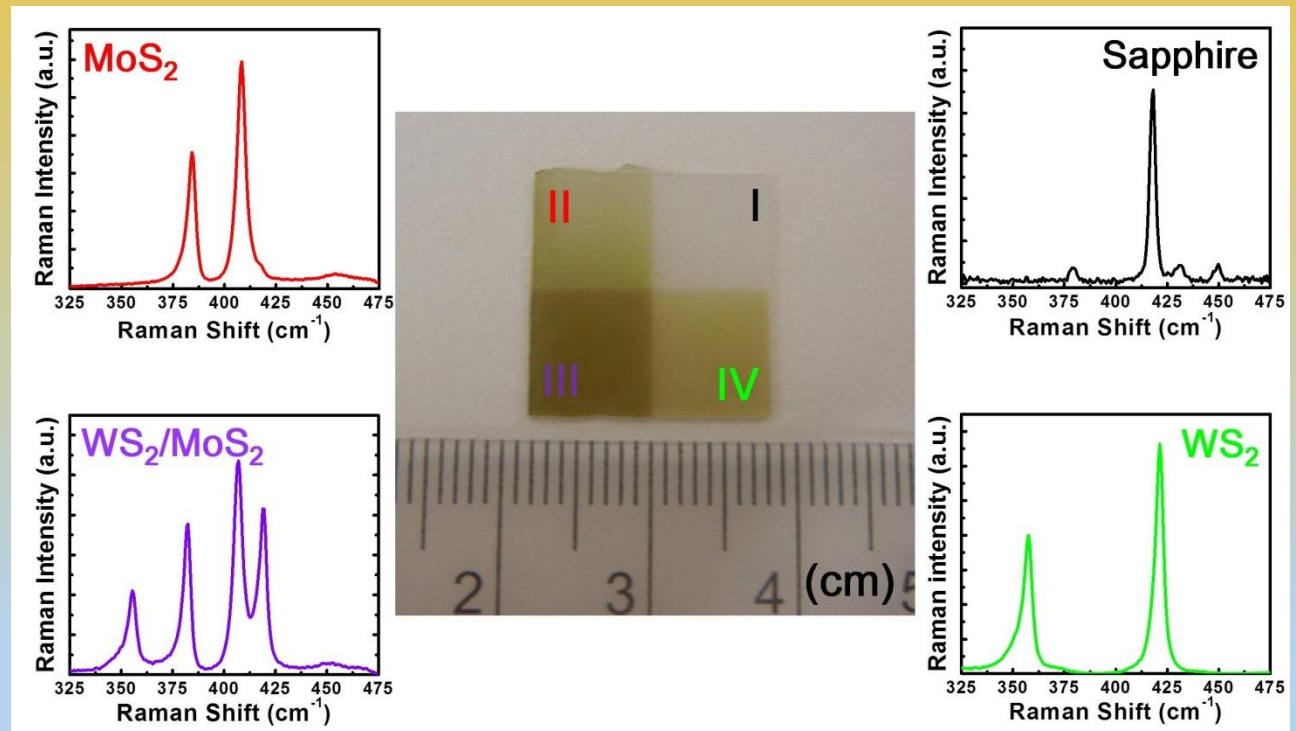
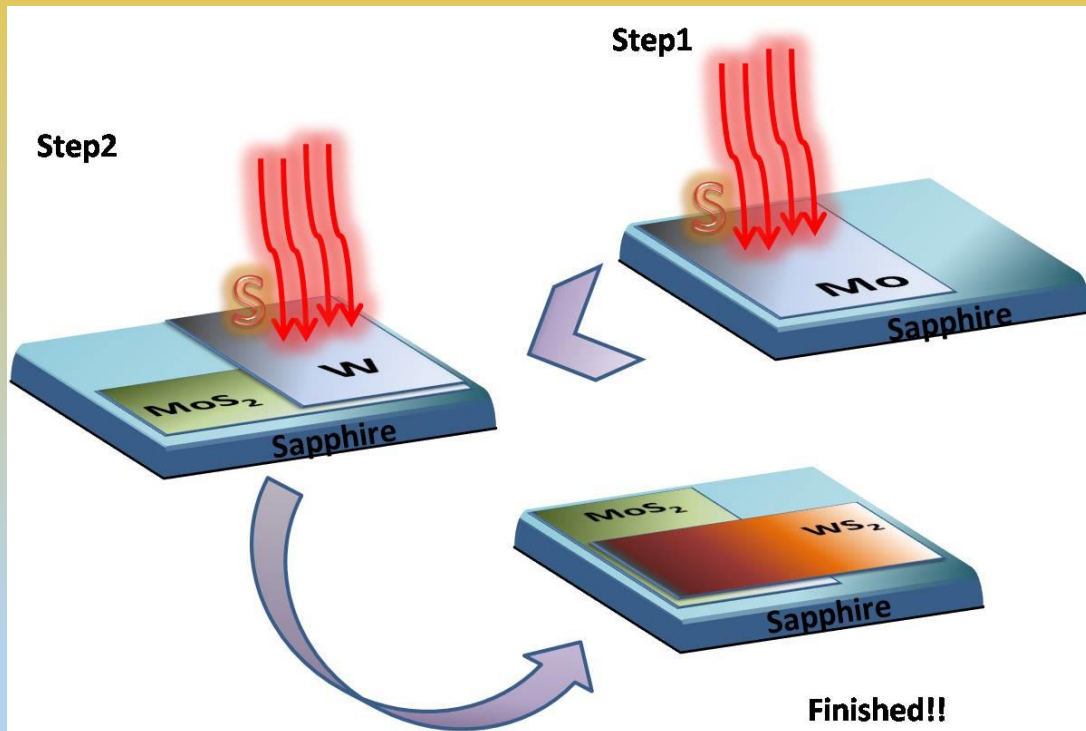
The Establishment of 2D Crystal Hetero-structures



The Band Diagram and Device Fabrication of WS₂/MoS₂ Hetero-structures



Selective Growth of 2D Crystals



Conclusion

- Large-area TMD films can be obtained
- Good layer number controllability
- The growth model for this growth technique
- The establishment of large-area 2D crystal hetero-structures and their device applications
- Selective growth of 2D crystals

Thank you for your attention

Acknowledgment

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